

AF/ITW
PATENT
Atty. Dkt. No. APPM/003177.D1/CPULB/PJS
Serial No.: 10/546,405

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Application of:
Wang, et al.

Serial No.: 10/646,405

Confirmation No.: 9508

Filed: 8/22/2003

For: Method and Apparatus For Ionized Plasma Deposition

Group Art Unit: 1753

Examiner: Rodney Glenn McDonald

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATE OF MAILING
37 CFR 1.8

I hereby certify that this correspondence is being deposited on April 10, 2006, with the United States Postal Service as First Class Mail in an envelope addressed to: Mail Stop AF, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

4/10/06
Date

Kevin R. White
Signature

Dear Sir:

SECOND RESPONSE TO FINAL OFFICE ACTION DATED JANUARY 10, 2006

In further response to the Final Office Action mailed January 10, 2006 and the Advisory Action dated March 28, 2006, having a shortened statutory period for response set to expire on April 10, 2006, please enter this response and reconsider the claims pending in the application for reasons discussed below. Although Applicant believes that no additional fees are due in connection with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/APPM/003177.D1/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper. **Remarks** begin on page 7 of this paper.